



## **Micronic Receives Order for LRS Pattern Generator from an Asian Customer**

TÄBY, Sweden – February 16, 2006 – Micronic Laser Systems AB (Stockholm Exchange's "O list": MICR), a leading global supplier of laser pattern generators for photomasks, has received an order for an LRS series pattern generation system from an Asian customer.

"As a leading supplier to Asia's display photomask producers, Micronic is well-positioned to meet our customers' needs in a continued strong display market," said Sven Lofquist, Micronic president and CEO.

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### **About Micronic Laser Systems AB**

Micronic Laser Systems AB is a Swedish high-tech company engaged in the development, manufacture and marketing of a series of extremely accurate laser pattern generators for the production of photomasks. The technology involved is known as microlithography. Micronic's product offering also includes metrology systems for display photomasks. Micronic's systems are used by the world's leading electronics companies in the manufacture of television and computer displays, semiconductor circuits and semiconductor packaging components. Micronic is located in Täby, north of Stockholm and at present has subsidiaries in the United States, Japan and Taiwan. Micronic maintains a web site at: <http://www.micronic.se>